

Substitute Specification

Marked Up Version

SPECIFICATION

[Title of Invention]

~~Vacuum evaporation deposition method of the winding type and vacuum evaporation deposition apparatus of the same~~ **VACUUM EVAPORATION DEPOSITION METHOD AND APPARATUS OF THE WINDING TYPE**

[Technical Field]

[0001] This invention relates to a vacuum evaporation deposition method of the winding type in which an insulting base film is continuously dispensed in a reduced pressure atmosphere, and cooled by a cooling roller in close contact, and a metal film is deposited on the insulating film and the metal-deposited film is wound up on a take-up roller.

[Background of the Technique]

[0002] In the prior art, such an evaporation deposition method of the winding type is known in which a long ~~material~~ base film of insulating material is continuously dispensed from a dispense roller, ~~passing~~ passed along in contact with a cooling can roller ~~in contact~~ and evaporation material from an evaporation source facing to the can roller is deposited on the ~~material~~ base film, and the deposited ~~material~~ base film is wound up on a take-up roller. That method is disclosed, for example, in the following patent literature 1.

[0003] In the vacuum evaporation deposition method of ~~such a~~ this kind, a ~~material base film of insulating material~~ is cooled in contact with the peripheral surface of a cooling can roller to prevent thermal deformation, and a film is formed on the cooled ~~material~~ base film. Accordingly, it is an important problem as to how the ~~material~~ base film is closely contacted with the cooling can roller, in the ~~such a~~ such a vacuum evaporation deposition method.

[0004] An arrangement to obtain a close contact between the material film and the cooling can roller is disclosed, for example, in the following patent literature 2. Fig.5 of the present disclosure shows a schematic construction of a film-forming apparatus of the winding type, described in the patent literature 2, in which the film is deposited by the plasma CVD method.

[0005] ~~Referred~~ Referring to ~~Fig5~~ Fig. 5, a dispense roller 3 with a wound base film 2 thereon, and on which a metal film is formed, a cooling can roller 4 and a take-up roller 5 are arranged in a vacuum chamber 1 under the reduced pressure. A reaction gas supply source 6 is arranged under the cooling can roller 4. A primary conductive thin film is formed on an insulating film 2, in the ~~film 2 with~~ form of a metal film. A reaction gas from a reaction gas supply source 6 reacts on the primary conductive thin film to ~~make form the~~ film formed. An insulating layer is formed on the surface of the can roller 4 which is made of metal. A predetermined negative potential is applied onto the roll body.

[0006] ~~And an~~ An electron beam radiator 7 is arranged between the dispensing roller 3 and the can roller 4, in the film-forming apparatus (plasma CVD) of the winding type as shown in Fig.5. A guide roller 8 is arranged between the electron beam radiator 7 and the can roller 4 to ~~connect~~ contact the conductive film of the film 2 to ~~the earth~~ ground. Thus, the film 2 with metal film applied is charged with the electron beam from radiator 7 onto the insulating layer surface thereof. The film 2 is closely contacted with the can roller 4, by the electrical attractive force between the can roller 4 and the film 2 with metal film.

[0007] Patent Document 1: JP7-118835A
Patent Document 2: JP2000-17440A

[Disclosure of Invention]

[Problem to be solved by the Invention]

[0008] However, only plastic film with conductive film already applied, such as the film 2 with metal film applied, is applicable for use in the prior art film-forming apparatus (plasma CVD) as shown in Fig.5. There is a problem that the prior art apparatus is not suitable for metal film deposition on a ~~material~~ base film such as plastics.

[0009] In the prior art film-forming apparatus (CVD) of the winding type, bias potential applied to the cooling can roller can be effective ~~to~~ on the film with metal film which is already formed thereon. However, when a metal film is newly deposited, the bias potential cannot be applied to the ~~material~~ base film before the metal film deposition. When only a material film is charged before the metal film is deposited, electric charges are diffused onto the deposited metal film during the metal deposition. ~~On-In that cause case,~~ the electro-static attractive force is lowered between the can roller and the material film and so the contact force is deteriorated.

[0010] Accordingly, the charge method and the bias application method employed in the prior art deposition apparatus of the winding type are not suitable for ~~the~~ metal film deposition on the ~~material~~ base film such as plastic film, and a high contact force cannot be obtained between the cooling can roller and the metal film. The ~~material~~ base film is shrunk and deformed due to the deficiency of the cooling effect of the ~~material~~ base film. The running speed of the ~~material~~ base film cannot be ~~risen-up~~ raised. Accordingly, the productivity cannot be improved.

[0011] This present invention has been made in consideration of the above problems. It is an object of this invention to provide a vacuum evaporation deposition method of the winding type and a vacuum evaporation deposition apparatus of the winding type in which ~~a~~ thermal deformation of a ~~material~~ base film such as ~~plastics~~ plastic is suppressed and a metal film can be formed at a high speed, ~~and-with~~ superior in productivity.

[Means for Solving Problem]

[0012] The above-described object can be achieved in accordance with the teachings of the present invention by a vacuum evaporation deposition method of the winding type in which a insulating material base film is continuously dispensed in ~~the~~ reduced pressure, ~~said material the~~ film is cooled by a cooling roller in contact therewith, and a metal film is deposited on ~~said material the base film, characterized in that said material~~ The film is made ~~closely~~ to be in close contact with ~~said the~~ cooling roller by electrifying ~~said material the base film~~ before the metal film deposition and ~~said material the~~ film is made ~~closely to~~ be in close contact with ~~said the~~ cooling roller by applying a voltage between ~~said the~~ metal film and ~~said the~~ cooling roller after the deposition of ~~said the~~ metal film.

[0013] Further, the object of this invention is achieved by a vacuum evaporation deposition apparatus of the winding type which includes a vacuum chamber, unwinding means for continuously dispensing a ~~material base~~ film, arranged in ~~said the~~ vacuum chamber, take-up means receiving ~~said material the base~~ film dispensed from ~~said the~~ unwinding means, a cooling roller for cooling ~~said material the~~ film in close contact, arranged between ~~said the~~ unwinding means and ~~said the~~ take-up means, and an evaporation source is arranged facing to ~~said the~~ cooling roller for depositing metal film on ~~said material the base film[,].~~ The invention is characterized in that ~~said the~~ apparatus ~~comprises includes~~ charged-particle irradiating means for irradiating charged-particles onto ~~said material the base~~ film, arranged between ~~said the~~ unwinding means and ~~said the~~ evaporation source, an auxiliary roller arranged between ~~said the~~ cooling roller and ~~said the~~ take-up means, for guiding the running of ~~said material the base~~ film in contact with ~~said the~~ deposited surface of ~~said material the base~~ film, and voltage applying means for applying a DC voltage between ~~said the~~ cooling roller and ~~said the~~ auxiliary roller.

[0014] Before deposition of metal film, ~~said material the base~~ film electrified with irradiation of the charged particles is made to be in close ~~contacted contact~~ to the cooling

roller, to which a bias potential is applied[,] by an electro-static attractive force. On the other hand, after deposition of the metal film, a ~~part-portion of the~~ charges on the base film ~~is-are~~ dissipated with the metal film ~~deposited~~ deposition. However, a potential is applied to the metal film in contact with said auxiliary roller. Thus, electro-static attraction occurs between ~~said-the~~ metal film and ~~said-the~~ cooling roller. Accordingly, ~~also-even~~ after the deposition of metal, an attraction force is maintained between ~~said-the~~ base film and ~~said~~ the cooling roller.

[0015] Thus, in this invention, a highly close contact force can be obtained between ~~said-the~~ base film and cooling roller both before and after ~~of-the~~ deposition of metal, and so the cooling efficiency of ~~said~~ the film can be maintained. Thermal deformation of ~~said-the~~ base film can be prevented ~~on-upon~~ the deposition of metal and the running speed of ~~said~~ film can be raised. ~~And-and~~ productivity can be improved.

[0016] On the other hand, when a bias potential becomes higher than a predetermined value between the cooling roller and the auxiliary roller or the metal film on the ~~material-base~~ base film, there occurs the fear that evaporation metal splashes ~~to-could~~ cause a short-circuit and thermal damage and ~~so-therefore~~ the quality ~~is-would be~~ deteriorated. Preferably, the surface potential of the deposited metal film is measured and a step to control the applied voltage is provided to ~~be-put-place it~~ within a predetermined range. Thus, the damage due to splash of depositing metal can be avoided. ~~And-so-the~~ and stabilization of quality can be obtained. ~~Said-This~~ predetermined range is within a range between a lower voltage limit suitable to obtain a ~~suitable~~ close contact force between ~~said~~ material-the base film and ~~said-the~~ cooling roller and an upper voltage ~~to-limit which will~~ avoid the damage due to splash ~~of-occurring in the~~ depositing method. It can be selected in accordance with the material of the base film, thickness of the base film and the film-running speed.

[Effect of the Invention]

[0017] According to this invention, a high contact force can be obtained between the insulating material base film and the cooling roller, both before and after the deposition of metal film. Thus, the thermal deformation of the insulating material film can be prevented. The film-running speed and the productivity can also be improved.

[Brief Description of the Drawings]

[0018] Fig. 1 is a schematic view of a vacuum evaporation deposition apparatus of the winding type 10 according to one embodiment of this invention;

Fig. 2 shows a film-forming surface of the insulating material base film. Fig. 2A shows the situation of formed oil pattern 25 and Fig. 2 B shows the situation after the deposition of the metal film 26;

Fig. 3 is a cross-sectional schematic view for explaining an electron beam radiating step applied to the insulating material base film 12;

Fig. 4 is a cross-sectional schematic view for explaining the attracting force between ~~said the~~ insulating material base film 12 and ~~said the~~ can roller 14 after the deposition of metal film;

Fig. 5 is a schematic view of a prior art vacuum evaporation deposition apparatus of the winding type.

~~[Explanations of Letters or Designations for Figure Reference Numerals]~~

- [0019]
- 10 vacuum evaporation deposition apparatus of the winding type
 - 11 vacuum chamber
 - 12 insulating material base film
 - 13 unwinding roller

- 14 can roller (cooling roller)
- 15 take-up roller
- 16 evaporating source
- 18 auxiliary roller
- 20 pattern forming unit (mask-forming means)
- 21 electron beam irradiator (charged-particle irradiating means)
- 22 DC bias electric source (voltage applying means)
- 23 electricity removal means for removing electricity
- 25 oil pattern
- 26 metal film
- 27 sensor (detecting means)
- 28 controller (controlling means)

[Best Embodiment of Invention]

[0020] Next, an embodiment of this invention will be described with reference to the drawings.

[0021] Fig. 1 is a schematic view of a vacuum evaporation deposition apparatus of the winding type according to ~~the~~an embodiment of this invention. The vacuum evaporation deposition apparatus 10 of the winding type ~~10~~ according to ~~the~~this embodiment is provided with a vacuum chamber 11, an unwinding roller 13 for ~~a~~an insulating material base film 12, a cooling can roller 14, a take-up roller 15 and an evaporation deposition source 16 of material to be deposited.

[0022] The vacuum chamber 11 is connected through a conduit portion 11a to a vacuum exhaust system including a vacuum pump (not shown). The interior of the vacuum chamber 11 is exhausted to a predetermined pressure and it is partitioned into two ~~rooms~~chambers by a partition wall 11b. The unwinding roller 13 and take-up roller 15

are arranged in the one of the ~~rooms~~chambers and the evaporation source 16 is arranged in another of the ~~rooms~~chambers.

[0023] The insulating material base film 12 is a long insulating plastic film cut into a predetermined width. OPP (orienting polypropylene) film is used in this embodiment. PET (polyethylene terephthalate) film, PPS (polyphenylene sulfide) film and a paper sheet can also be used.

[0024] The insulating material base film 12 is dispensed from the unwinding roller 13 and wound up on the take-up roller 13 after passing through plural guide rollers 17, a can roller 14, and an auxiliary roller 18 and plural guide rollers 19. The ~~above~~ unwinding roller 13 and the take-up roller 15 correspond to ~~a~~the unwinding means and a take-up means of this invention. Although not shown, ~~rotation~~rotary drives are ~~arranged at~~provided to drive the unwinding roller 13 and the take-up roller 15, respectively.

[0025] The can roller 14 is cylindrical in shape and it is made of metal such as stainless. A cooling mechanism, such as a circulating system of cooling water, a rotational drive mechanism for driving can roller 14 and etc, are included in the can roller 14. The insulating material base film 12 is wound ~~on~~about the can roller 14, ~~at~~and in a predetermined angle range ~~and~~ evaporating material from the evaporating source 16 is deposited on the outside surface of the material film 12, and at the same time, the material film 12 is cooled by the can roller 14.

[0026] The evaporating source 16 contains material to be deposited. It is heated by a resistance heater, inductive heater, electron beam or ~~the~~a prior art heating method. A depositing material is heated in the evaporation deposition source 16, which is arranged under the can roller 14. The evaporation material from the source 16 is deposited onto the insulating material base film 12 wrapped ~~on~~over the can roller 14.

[0027] Metal elements such as Al, Co, Cu, Ni, and, Ti and further Al-Zn, Cu-Zn and Fe-Co alloys made of two or more kinds of metal or metal alloy may be used. Plural evaporation sources may be ~~arranged-provided~~ instead of one evaporation source.

[0028] The vacuum evaporation deposition apparatus 10 of the winding type according to this embodiment is provided further with a pattern forming unit 20, an electron beam irradiator 21, a DC bias source 22 and an electricity removing unit 23.

[0029] The pattern forming unit 20 forms a region ~~to be deposited with for the deposition of~~ metal film on the insulating material base film 12. It corresponds to the “mask forming means” of this invention arranged between the unwinding roller 13 and the can roller 14.

[0030] Fig. 2 shows the film-forming surface of the insulating material base film 12. The pattern forming unit 20 forms an oil pattern 25 as shown by hatching in Fig.2A. Plural rows of oil are formed as coated on the insulating material base film 12 along the running direction or lengthwise direction. Rectangular metal patterns 25 are formed by the deposition of the material from the evaporation deposition source 16 in opening portions 25a. They are connected through connecting portions 26a at a predetermined pitch. Thus, the plural rows of metal film 26 are formed on the insulating material base film 12 as shown in Fig.2B. Of course, the pattern of the deposited metal film is not limited to the shape ~~as shown on~~ in Fig.2.

[0031] The electron beam irradiator 21 corresponds to the “charged-particles radiating means” of this invention. Electron beams, as charged particles, are irradiated onto the insulating material base film 12, and ~~so therefore~~ it is negatively charged. Fig.3 is a cross-sectional schematic view for explaining the radiating step of the electron beam onto the insulating material base film 12. In this embodiment, the electron beam irradiator 21 is arranged facing to the peripheral surface of the can roller 14. The electron beams are

irradiated onto the surface ~~to be deposited~~, of the insulating material base film 12. Since the electron beams are irradiated onto the ~~material~~-film 12 which is in contact with the can roller 14, the ~~material~~-film 12 is being cooled[,] and receives electron ~~beam~~-beams.

[0032] In this embodiment, the electron beam irradiator 21 scans a radiating electron beam on the insulating material base film 12 in the width direction of the ~~material~~-film 12. Thus, the ~~material~~-film 12 is prevented from ~~damages~~-damage due to local irradiation of the electron beam onto the insulating material base film 12. Thus, the ~~material~~-film 12 can be charged uniformly and effectively.

[0033] A predetermined DC voltage is applied between the can roller 14 and the auxiliary roller 18 by the DC bias power source 22, which ~~correspond~~-corresponds to the "voltage applying means" of this ~~Invention~~-invention. In the embodiment, the can roller 14 is connected to a positive electrode of the DC power source 22 and the auxiliary roller 18 is connected to a negative electrode of the DC power source 22. Thus, the insulating material base film 12 is negatively charged by the radiation of the electron beam and is electrostatically attracted to the surface of the can roller 14 as shown in Fig.3. Thus, the ~~material~~-base film 12 is contacted closely with the can roller 14.

[0034] The auxiliary roller 18 is made of metal and the peripheral surface of the auxiliary roller 18 ~~contacts~~-rolling on-is in rolling contact with the deposition surface of the insulating material film 12.

[0035] Fig.4 is a cross-sectional schematic view for explaining the attraction between the ~~material~~-base film 12 after deposition and the can roller 14. ~~Pattern like A~~ pattern such as metal film 26 is formed on the ~~material~~-base film 12 by the deposition. The metal film 26 is continuous in the longitudinal direction as shown in Fig.2B. The auxiliary roller 18 is connected to the negative electrode of the DC voltage source 22. It guides the ~~material~~-base film 12 on the metal film side. ~~Negative~~-A negative potential is applied to the metal film in

contact with the peripheral surface of the auxiliary roller 18 on the deposited surface of the metal film 26 as shown in Fig.2B. As ~~the a~~ result, polarization occurs in the material base film 12 interposed between the metal film 26 and the can roller 14, ~~polarization occurs.~~ ~~And so~~ Accordingly an electro-static attractive force occurs between the insulating material base film 12 and the can roller 14. ~~And so and therefore a~~ close contact force is obtained between the can roller 14 and the insulating material base film 12.

[0036] Particularly in this embodiment, the DC bias power source 22 is variable. The potential applied onto the metal film 26 of the insulating material base film 12 is monitored to stabilize the voltage applied to the metal film 26. Thus, ~~it can be avoided that lowering of~~ the contact force of the material base film 12 to the can roller 14 ~~is lowered~~ due to variation of the applied voltage to the metal film 26, and a short-circuit is made between the metal film 26 and the can roller 14 ~~to~~, which can cause splash and damage, are avoided.

[0037] In this embodiment, the vacuum evaporation deposition apparatus 10 of the winding type is provided with a sensor 27 for detecting the surface potential of the metal film 26 on the material base film 12 at the upper-up stream side of the auxiliary roller 18 with respect to the film running direction[,], and ~~a the~~ controller 28. It receives the output of the detecting sensor 27 and controls the DC bias voltage source 22 so that the potential of the metal film 26 is put placed within a predetermined range.

[0038] The predetermined range is between the lowest permissible voltage, ~~so which~~ is sufficiently high as to obtain the suitable close contact force of the insulating material base film 12 to the can roller 14, and the highest permissible voltage ~~to bring, which is~~ sufficiently low so as not to cause splash damages of damage to the depositing metal. It can be suitably selected in accordance with the kind of insulating material base film 12, the thickness thereof and the film running speed, etc.

[0039] A surface potential meter of the type for measuring film surface potential is used as the sensor 27. An electrode in the measuring probe is vibrated and displacement current in accordance with the film surface potential is induced in the probe electrode. This invention is not limited to the construction used for controlling the ~~applying-applied~~ voltage in accordance with a film surface potential. For example, the ~~applying-applied~~ voltage may be so controlled by measuring the temperature of the ~~material-base~~ film 12.

[0040] The electricity-removing unit 23 corresponds to the electricity-removing means of this invention. It is arranged between the auxiliary roller 18 and the take-up roller 15. It has the function to remove electricity due to electron beam irradiation from the electron beam irradiator 21. In one example of the electricity-removing means, the running insulating material base film 12 is plasma-bombarded to remove ~~the electricity on of the material-film~~ 12.

[0041] Next, the evaporation deposition method of the winding type will be described together with the operations of the evaporation deposition apparatus of the winding type 10 according to the embodiment of this invention.

[0042] The insulating material base film 12 is continuously dispensed from the unwinding roller 13. It ~~is passing passes~~ through the oil-pattern forming process provided by the oil-pattern forming unit 25, the electron beam radiating process, the evaporation deposition process and the electricity-removing process and is continuously received by the take-up roller 15.

[0043] In the mask forming process, the oil pattern 25 is coated on the ~~material-base~~ film 12, for example, in the shape as shown in Fig.2A by the pattern-forming unit 20. Instead, such a mask forming method can be employed ~~that whereby~~ a transcription roller rolls on the ~~material-base~~ film 12 to transcribe a necessary pattern thereon.

[0044] The insulating material base film 12 with the oil pattern formed thereon is wrapped ~~onto-over~~ the can roller 14. Near the position of the contact start with the can roller 14, the ~~material~~-film 12 is irradiated with the electron beam from the electron beam irradiator 21, and ~~so~~-it is therefore negatively charged. Since the ~~material-base~~ film 12 is irradiated with the electron beam at ~~the-a~~ position of ~~the~~-contact with can roller 14, the material film 12 can be effectively cooled by the can roller 14. Further, since the electron beam is irradiated by scanning[,] on the ~~material-base~~ film 12 in the width direction, the thermal deformation of the ~~material~~-film 12 can be avoided, and further it can be uniformly and effectively charged.

[0045] The insulating material base film 12 is negatively charged by ~~the~~-irradiation of the electron beam and is electro-statically attracted and contacted closely with the can roller 14 biased positively by the DC bias voltage source 22, as shown in Fig.3. Material to be deposited, evaporated from the evaporation material source 16, ~~is piled on~~-applied to the surface[,] of the ~~material-base~~ film 12. Thus, the metal film 26 as stripes as shown in Fig.2B is formed on the ~~material-base~~ film 12. Plural rows of the stripes are connected through the connecting portions 26, ~~extended~~-extending in the lengthwise direction of the ~~material~~-film 12.

[0046] The negative potential of the DC bias voltage source 22 is applied through the auxiliary roller 18 to the metal film 26 formed on the ~~material-base~~ film 12. After the deposition of the metal film 26, the one surface of the ~~material-base~~ film 12 wrapped ~~on~~ over the can roller 14 ~~at-on~~ the same side of the metal film 26 is positively polarized, and the other surface of the ~~material-base~~ film 12 ~~at-on~~ the same side of the can roller 14 is negatively polarized. Thus, an electro-static attractive force occurs between the ~~material base~~ film 12 and the can roller 14. As ~~the-a~~ result, the ~~material-base~~ film 12 is closely contacted with the can roller 14.

[0047] As above described, in this embodiment, the insulating material base film 12 in close contact with the can roller 14 is charged with the irradiation of the electron beam before the deposition of the metal film 26, ~~to be closely contacted with the can roller 14.~~ After the deposition[,] of the metal film 26, the ~~material base~~ film 12 is closely contacted with the can roller 14 with the bias voltage applied between the metal film 26 and the can roller 14. Although a ~~part portion~~ of the charges (electrons) on the ~~material base~~ film 12 are charged before the deposition of the metal film 26 ~~is discharged~~ and dissipated into the metal film during the deposition of the metal on to the ~~material base~~ film 12, all or a ~~part portion~~ of the dissipated charges ~~is are~~ compensated with the application (supply of the electrons) of the negative potential to the metal film 26 from the auxiliary roller 18.

[0048] Accordingly, according to the embodiment of this invention, the decrease of the contact force between the ~~material base~~ film 12 and the can roller 14 is suppressed also after the evaporating deposition step, and so ~~the~~ stable cooling operation of the ~~material base~~ film 12 can be secured both before the evaporating deposition and after evaporating deposition. Thus, the thermal deformation of the ~~material~~-film 12 can be avoided during the evaporation deposition of the metal film. The running speed of the ~~material~~-film 12 and the metal film forming speed can be raised. Thus, the productivity can be improved. This embodiment is particularly useful for ~~the an insulating material base~~ film 12 made of material ~~being which is~~ hard to be charged, with the metal film deposited, such as OPP film. When the metal film 26 is ~~pattern likely pattern~~ formed on the ~~material~~-film 12 as in this embodiment, the temperature is ~~locally raised~~ locally, and the amount of the charges sometimes varies. The discharged metal film-forming portion is compensated with the bias voltage and so the contact force between the insulating material film and the can roller can be strengthened. That is advantages, because the insulating material base film 12 is uniformly cooled.

[0049] Further in this embodiment, since the voltage applied between the can roller 14 and the auxiliary roller 18 is controlled on the basis of the surface potential of the metal film 26 on the ~~material-base~~ film 12, the close contact between the ~~material-base~~ film 12 and the can roller 14 can be stably maintained and ~~the~~ thermal damage such as splash can be avoided.

[0050] The metal film 26 is deposited on the insulating material film 12 in the above described manner. It is subject to ~~the~~ electricity removal by the electricity removal unit 23 and is then taken up onto the winding roll 15. Thus, the stable winding operation of the insulating material film 12 can be secured and the insulating material film can be prevented from shrinking or wrinkling due to the electricity.

[0051] Next, ~~the~~ an example of this invention will be described.

[0052] The maximum driving speed permissible was measured at which the metal film can be formed on the insulating material film 12 without thermal deformation such as shrink or wrinkle. ~~In in~~ the case of only the bias voltage being applied, in the case of only the electron beam radiation being applied, and in the case of applying the bias voltage plus electron beam radiation (this invention), respectively.

Insulating material film 12 : OPP film 600mm width, 4.m thickness. Metal AL film: film thickness of sheet resistance 2 /..

Electron beam irradiator : Electron beam gun of the scanning type 4KV X 100.200mA , scanning frequency 1000Hz. And DC bias voltage source 22 : 100.120V.

[0053] The results of the experiment are as follows:

The case of only bias voltage: 300m/min.

The case of only electron beam radiation: 250 m/min.

The case of the bias voltage plus electron beam radiation: 500m/min.

[0054] Thus, it has been proved according to this invention that the close contact of the insulating material film 12 with the can roller 14, can be securely obtained and the driving speed can be raised with the additional effect of the bias voltage application and the electron beam radiation.

[0055] While the preferred embodiments of the Invention have been described, without being limited to this, variations thereto will occur to those skilled in the art within the scope of the present inventive concepts that are delineated by the following claims.

[0056] For example, in the above embodiment, the metal film 26 is deposited on the insulating material film 12 in the shape of stripes connected through the connecting portions 26a as shown in Fig. 2B. The pattern is not limited to the type shown ~~type~~. For example, linear patterns along the lengthwise direction of the insulating material film can be employed in-within the scope of this invention or a metal film may be formed as single layer ~~and-with a~~ uniform patternless shape[,] on the insulating material film 12.

[0057] Further, in the above embodiment, the electron beams are irradiated on the insulating material film 12 to negatively charge the film. Instead of the electron beam, ions may be irradiated on the insulating material film 12 to positively charge the film. In this case, polarities applied between the can roller 14 and the auxiliary roller 18 are ~~inverted-reversed~~ from the above embodiment. Thus, the can roller 14 is connected to the negative electrode and the auxiliary roller 18 is connected to the positive electrode.